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Synthesis of Photoactive Ternary Cadmium Sulfoselenide Thin Film via Cost-effective Chemical Technique for Solar Cell Application



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Abstract

We have successfully developed arrested precipitation technique for synthesis of photoactive $Cd(S_{0.8}Se_{0.2})$ thin film. Synthesized thin film were characterized for optical, structural, morphological and compositional analysis using UV–Vis spectrophotometer, Xray Diffraction (XRD), Field-Emission Scanning Electron Microscopy (FESEM) and Energy Dispersive Spectroscopy (EDS) analyzer techniques. Optical study shows linear nature of plot confirms direct allowed transition with optical band gap energy 2.13eV. Pure phase hexagonal nanocrystalline thin film formation confirmed through XRD pattern. FESEM micrographs indicate construction of void free and well-adherent twisted nest-like surface morphology containing tremendous grown flakes over substrate. Presence of Cd^{2+} , S^{2-} and Se^{2-} elements confirmed by EDS spectrum. Finally, synthesized thin film show power conversion efficiency of 0.37 %.

Keywords: APT; Nanocrystalline; n-CdSSe; Thin film; Pure phase; $\eta = 0.37\%$

Abbreviations: XRD: Xray Diffraction; FESEM: Field-Emission Scanning Electron Microscopy; CBD: Chemical Bath Deposition; CCGP: Controlled Chemical Growth Process; APT: Arrested Precipitation Technique

Introduction

In past few years, the world serious energy and environmental crisis have made more attention to development of new cost-effective and sustainable energy source [1]. Also, quest for new alternative renewable energy source is quite argent and necessary. Overall available technologies photoelectrochemical solar cell technology has believed to be cost-effective and renewable energy source for solar energy conversion. Generally, photoelectrochemical performance of semiconducting materials depends on their respective properties and essential physiochemical processes in which, i) Absorption of light radiations, ii) separation of charge carriers, iii) migration of carriers, iv) recombination of charge carriers and v) redox reaction. Also, respective properties of semiconducting material are nothing but, electronic band structure, crystal structure, chemical constituents and their microstructures.

II-VI group semiconducting compounds are the most important and highly studied semiconducting material for scientific and technological point of application due to their direct band gap [2]. Among this *II-VI* group semiconducting compounds, typically CdS and CdSe have 2.40 and 1.70 eV optical band gap with wide absorption band edge and excellent absorptivity in visible region [2].

These ternary CdSSe thin films synthesized by varied of method such as, sputtering [3], Chemical Bath Deposition (CBD) method [4]and solvathermal route [5]. All these methods require highly sophisticated instruments, harsh experimental condition, different surface directing agents and solvents [6]. However, in Arrested Precipitation Technique (APT) their no need to use sophisticated instrument, different solvents and harsh experimental condition. Taking into concern these features of technique, we have used APT method for synthesis of CdSSe thin films. APT method is nothing but hybrid chemical process of CBD and Controlled Chemical Growth Process (CCGP) [7].

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In present investigation, we have successfully deposited $Cd(S_{0.8}Se_{0.2})$ thin film using triethanolamine as complexing agent at via APT method. Our intension is to make efficient photoelectrode for photoelectrochemical application using triethanolamine as surface directing agent. Synthesized thin film show 0.37% power conversion efficiency under illumination of 500W tungsten filament lamp (intensity 30mW cm⁻²). Also, thin film formation growth process by using APT is discussed detailed.

Experimental

Chemicals

All chemicals were of analytical reagent (AR) grade and used without further purification. Cadmium sulfate hydrate $(CdSO_4.H_2O)$ (98%, S-D Fine Chem.), thiourea $(H_2N-CS-NH_2)$ (99%, S-D Fine Chem.) selenium metal powder (99.5%, Sigma Aldrich), sodium sulfite (Na_2SO_3) (96%, S-D Fine Chem.), liquor ammonia (NH_3) (28-30% Thomas Baker), and triethanolamine $(N(CH_2CH_2OH)_2)$ (99%, Merck).

Synthesis of $Cd(S_{0.8}Se_{0.2})$ thin film

In typical synthesis, initially Cd-TEA complex was prepared by triturating 'Cd' with TEA as complexing agent for 6 h homogenous crushing to form clear Cd-TEA complex. All metal ions and chalcogen ions precursors' concentration is optimized at initial stage of synthesis as 0.05M. Cd-TEA complex release Cd²+ metal ions slowly and react with S²- and Se²- chalcogen ions released from dissociation of $\rm H_2N\text{-}CS\text{-}NH_2$ and $\rm Na_2SeSO_3$ at alkaline pH, 10.4, and $\rm 50\pm2$ °C bath temperature at 2.30h deposition time. Formation of thin films is well dependant on various preparative parameters such as, deposition time, bath temperature, pH and precursor concentration. These parameters were optimized during initial stage of thin film synthesis.

After desired deposition time deposited film was removed from bath and washed with double distilled water and dried at room temperature in air. Deposited film was yellowish red in colour and designated as $Cd(S_{0.8}Se_{0.2})$.

Characterization of thin film

Thickness of film was measured using surface profiler (AMBIOS XP-1). Optical absorption spectra were taken by using a UV-Vis-NIR spectrophotometer (Shimadzu, UV-1800). Structural properties and crystallite size were carried out using an X-ray diffractometer (Bruker AXS, D8) using Cu Ka (l= 1.5418 Å). Surface morphology and the elemental composition of the as-deposited thin films were characterized using field-emission scanning electron microscopy (FESEM) equipped with an energy dispersive X-ray spectroscopy (EDS) analyzer (Hitachi, S-4700). PEC measurements were carried out using a semiconductor parameter analyzer (Keithley SCS-4200 Semiconductor) characterization unit using 500 W tungsten filament lamp (intensity 30mW cm⁻²) with sulfide/polysulfide electrolyte.

Results and Discussion

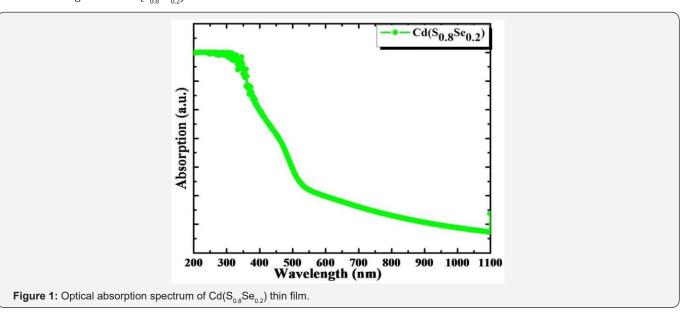
Formation Growth mechanism

Main principle behind the film formation is slow ion-byion condensation of ions followed by multi nucleation process. Precipitation of metal chalcogenide thin films is occurred when ionic products (Kp) of Cd²⁺, S²⁻ and Se²⁻ ions exceed solubility product (Ksp) of Cd(SSe) in films. Slow release of metal and chalcogen ions from respective complex results into highquality and well-adherent thin films formation [7-9].

Optical absorption studies

Figure 1 shows optical absorption spectrum of $Cd(S_{0.8}Se_{0.2})$ thin film recorded using UV-VisNIR spectrophotometer in 200-1100nm wavelength range. Maximum light absorption edge observed at 650nm. Fundamental absorption corresponds to electron excitation from valance band to conduction band, used to determine value of optical band gap energy. Optical data were demonstrated using following eq. (1) as follows,

$$\alpha = \frac{A(h\theta - Eg)^n}{h\theta} \tag{1}$$



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where, A is a parameter that depends on the transition probability, h is Planck constant, Eg is optical band gap energy of material, and exponent depends on the type of transition. The values of n for direct allowed, indirect allowed, direct forbidden and indirect forbidden transitions are 1/2, 2, 3/2 and 3, respectively (Figure 1).

From optical absorption spectrum clearly demonstrated

that linear nature of plot confirms direct allowed type transition mechanism.

Figure 2 shows plot of $(ah\vartheta)^2 vs$ photon energy $(h\vartheta)$, value of optical band gap was calculated by extrapolating straight-line portion to X-axis. Obtained optical band gap energy is 2.13 eV, which is consistent with other reported ternary CdSSe thin films [7]. 3.3. X-ray diffraction study

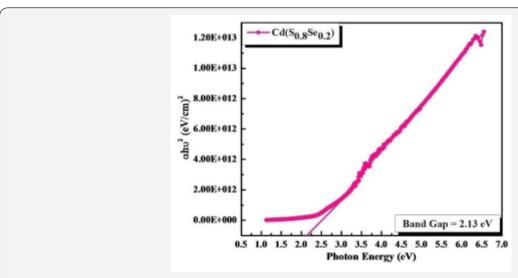


Figure 2: Plot of optical Band Gap energy.

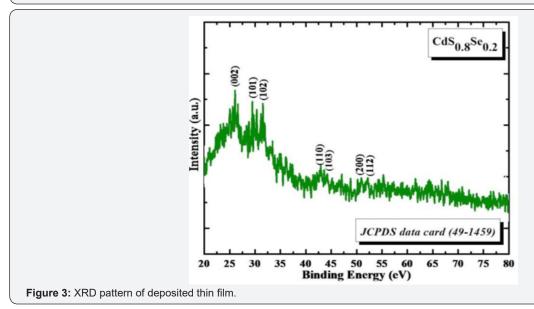


Figure 3 indicates typical X-ray diffraction pattern of $Cd(S_{0.8}Se_{0.2})$ thin film deposited by using APT method. All diffraction peaks are corresponding to (002), (101), (102), (110), (103), (200) and (112) at 2θ 26.02° , 28.40° , 31.13° , 42.80° , 44.93° , 50.89° and 52.07° of hexagonal crystal structure. Calculated d-values are in well-agreement with standard d-values (JCPDS card no. 49-1459) for an (hkl) plane, confirms formation of thin films with a pure phase material.

Crystallite size is calculated by using known Scherrer formula and calculated crystallite size is 55nm. Thickness of thin film is

728nm measured by using surface profiler analysis. Crystalline nature and phase pure formed thin films are highly favorable for enhanced light absorption in solar cell application [8].

Field emission scanning electron microscopy

Surface morphology of thin films carried out by using FESEM study. Figure 4 demonstrates FESEM micrographs at different resolution of $Cd(S_{0.8}Se_{0.2})$ thin film. Low resolution FESEM image of Figure 4 (a) point out void free and well adherent film formation occurs via APT method. It shows twisted nest-like surface morphology is observed overall substrate surface.

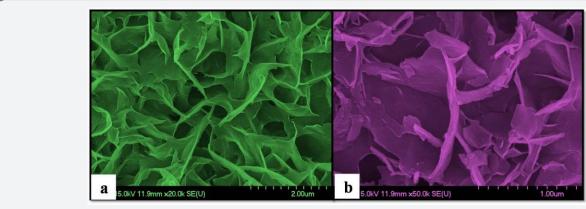
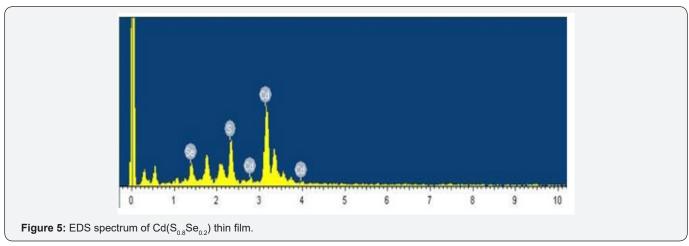


Figure 4: FESEM micrographs, (a) Low resolution FESEM image and (b) High resolution FESEM image.

High resolution FESEM images of Figure 4(b) clearly illustrate that twisting of nest-like morphology with irregularly grown sharp edged flakes. Such huge number of flakes winds together and formation of large network of nest-like morphology is

observed from high resolution micrograph. This obtained surface morphology is beneficial for improve light absorption potential may due to crystalline nature and large surface area of nest-like morphology with twisted flakes [9].

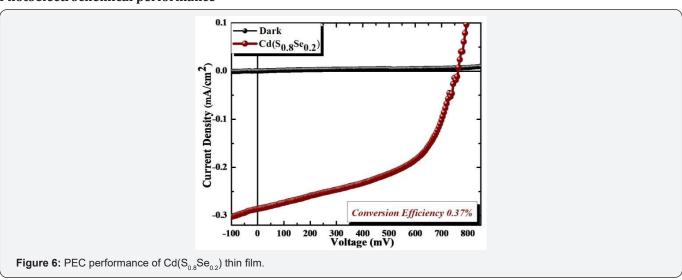
Energy dispersive spectroscopy



Quantitative analysis of element is confirmed through EDS study. Figure 5 shows typical EDS spectrum of deposited thin film.

EDS spectrum shows peaks at 3.13, 2.50 and 1.38 keV confirm the presence of Cd, S and Se elements respectively [7].

Photoelectrochemical performance



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PEC performance of $Cd(S_{0.8}Se_{0.2})$ thin film was measured with standard two-electrode system. Figure 6 shows J-V curve of PEC cells. PEC performance was measured by forming $Cd(S_{0.8}Se_{0.2})$ thin film as working photoelectrode with active area $1 \, \text{cm}^2$ and graphite rod (G) as counter electrode in 0.5M sulfide/polysulfide redox electrolyte. J-V measurements were done under illumination of light using 500 W tungsten filament lamp (Intensity of $30 \, \text{mW/cm}^2$). In dark, J-V curve shows diode-like rectifying characteristics. Upon illumination, curve is obtained at fourth quadrant, indicating

Table 1: PEC parameter of Cd(S_{0.8}Se_{0.2}) thin film.

generation of electricity and n-type conductivity nature [6-7].

Fill factor (FF) and power conversion efficiency (η %) of thin film were calculated by using equations (2) and (3) as follows,

$$FF = \left(\frac{J_{\text{max}} \times V_{\text{max}}}{J_{\text{sc}} \times V_{\text{oc}}}\right) \tag{2}$$

$$\eta(\%) = \left(\frac{J_{sc} \times V_{oc}}{P_{in}} \times FF \times 100\right)$$
(3)

Sample Code	Eg (eV)	Jsc (mA cm ⁻²)	Voc (mV)	Jmax (mA cm ⁻²)	Vmax (mV)	FF	η (%)
CdS _{0.8} Se _{0.2}	2.13	0.288	765	0.184	603	0.5	0.37

where, J_{max} and V_{max} are maximum short-circuit current density and maximum open circuit voltage, P_{in} is input light intensity (30mW/cm²). Jsc is short-circuit current density and V_{oc} is open circuit voltage. From J-V measurement, short circuit current density (J_{sc}) is 0.288mA cm² and that of open circuit voltage (V_{oc}) 765mV. Calculated power conversion efficiency is 0.37% for Cd($S_{0.8}Se_{0.2}$) thin film. Overall obtained conversion efficiency might be due to good crystallinity and developed surface morphology with large surface area [9]. Table 1 shows calculated PEC parameter.

Conclusion

Developed facile, cost-effective APT method shows potential for synthesis of thin films for solar cell. Synthesized thin film show promising properties favorable for photoelectrochemical performance is investigated. Optical study showed light absorption in visible region of solar spectrum and direct allowed transition mechanism. From XRD pattern it confirmed that formation of pure phase hexagonal crystal structure with nanocrystalline nature. FESEM analysis demonstrated synthesized surface morphology is void free and having large surface area for efficient light absorption. EDS pattern confirmed presence of Cd²⁺, S²⁻ and Se²⁻ elements in synthesized thin film. PEC performance indicated conversion efficiency of 0.37%.

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